

## WAFER EDGE EXPOSING APPARATUS

### ABSTRACT OF THE DISCLOSURE

A wafer edge exposing apparatus comprising: a light source  
5 device for generating source light; an optical fiber cord for guiding  
the source light generated from the light source into a light focusing  
device; a lens, positioned in the light focusing device to receive the  
source light from the optical fiber cord, the light focusing device to  
focus the source light to the edge of a wafer; and a wavelength  
10 converter for converting a wavelength of the source light to a  
wavelength corresponding to the highest absorptivity of a photoacid  
generator of resist coated on the wafer.